

Substitute Form PTO-1449 U.S. Department of Commerce Modified) Patent and Trademark Office				
by Ap	cl sure Statement oplicant	Applicant Kusumoto, et al.		
(Us s v ral st	neets if necessary)	Filing Date September 3, 1999	Group Art Unit 2822	

U.S. Patent Documents							
Examiner Initial	Desig. ID	Patent Number	Issue Date	Patentee	Class	Subclass	Filing Date If Appropriate
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	Foreign Patent Documents or Published Foreign Patent Applications							
Examiner	Desig.	Document	Publication	Country or			Translat	tion
Initial	ID d	Number	Date	Patent Office	Class	Subclass	Yes	No
wil	AL	58-015227	1/28/83	Japan			Abstract only	
	AM							
	AN							
	AO							

	Other Documents (include Author, Title, Date, and Place of Publication)					
Examiner Initial	Desig. ID	Document				
	AQ					
	AR					
	AS					
	AT					

Examiner Signature	Date Considered
lulia P. Waldonso	61/64/A203
EXAMINER: Initials citation considered. Draw line through citation if no	ot in conformance and not considered. Include copy of this form with
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Substitute Form PTO-1449 (Modified)	U.S. Department of Commerce Patent and Trademark Office	Attorney's Docket No. 07977/076002/US3130/3134D1	Application No. 09/390,513	
Inf rmati n Disclosur Statement by Applicant		Applicant Kusomoto, et al.		
	neets if necessary)	Filing Date September 3, 1999	Group Art Unit 2814	

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Examiner Initial	Desig. ID	Document Number	Publication Date	Country or Patent Office	Class	Subclass	Trans	lation No
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